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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/676,208	10/01/2003	Mei Wen	007135/CMP/ECP	7685
41161	7590	02/27/2007	EXAMINER	
DUGAN & DUGAN, PC 55 SOUTH BROADWAY TARRYTOWN, NY 10591			WONG, EDNA	
			ART UNIT	PAPER NUMBER
			1753	

SHORTENED STATUTORY PERIOD OF RESPONSE	MAIL DATE	DELIVERY MODE
3 MONTHS	02/27/2007	PAPER

**Please find below and/or attached an Office communication concerning this application or proceeding.**

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

**Office Action Summary**

Application No.

10/676,208

Applicant(s)

WEN ET AL.

Examiner

Edna Wong

Art Unit

1753

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --  
Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

**Status**

- 1) ☒ Responsive to communication(s) filed on 02 February 2007.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

**Disposition of Claims**

- 4) ☒ Claim(s) 1-28 is/are pending in the application.
- 4a) Of the above claim(s) 5-28 is/are withdrawn from consideration.
- 5) ☐ Claim(s) \_\_\_\_\_ is/are allowed.
- 6) ☒ Claim(s) 1-4 is/are rejected.
- 7) ☐ Claim(s) \_\_\_\_\_ is/are objected to.
- 8) ☐ Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement.

**Application Papers**

- 9) ☒ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on \_\_\_\_\_ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.  
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

**Priority under 35 U.S.C. § 119**

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some \* c) ☐ None of:
- ☐ Certified copies of the priority documents have been received.
  - ☐ Certified copies of the priority documents have been received in Application No. \_\_\_\_\_.
  - ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
- \* See the attached detailed Office action for a list of the certified copies not received.

**Attachment(s)**

- 1) ☒ Notice of References Cited (PTO-892)
- 2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948)
- 3) ☒ Information Disclosure Statement(s) (PTO/SB/08)  
Paper No(s)/Mail Date October 29, 2003.
- 4) ☐ Interview Summary (PTO-413)  
Paper No(s)/Mail Date. \_\_\_\_\_.
- 5) ☐ Notice of Informal Patent Application
- 6) ☐ Other: \_\_\_\_\_.

***Election/Restrictions***

Applicant's election without traverse of Group I, claims **1-4**, in the reply filed on February 7, 2007 is acknowledged.

The requirement is still deemed proper and is therefore made FINAL.

Accordingly, claims **5-28** are withdrawn from consideration as being directed to a non-elected invention.

***Specification***

The disclosure is objected to because of the following informalities:

page 2, line 31, it is unclear what is meant by "no nonexistent".

Appropriate correction is required.

The lengthy specification has not been checked to the extent necessary to determine the presence of all possible minor errors. Applicant's cooperation is requested in correcting any errors of which applicant may become aware in the specification.

***Claim Rejections - 35 USC § 102/103***

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

Art Unit: 1753

A person shall be entitled to a patent unless –

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

Claims **1-3** are rejected under 35 U.S.C. 102(e) as anticipated by or, in the alternative, under 35 U.S.C. 103(a) as obvious over **Dubin et al.** (US Patent No. 7,001,641 B2).

Dubin teaches a method comprising:

- (a) providing a substrate **230** having a metal seed layer **250**;
- (b) applying an agitated rinse **300** (= a wash liquid introduced at a rate of between about 0.2 liters/minute (l/m) and about 2 l/m) to the metal seed layer (= for washing away any deteriorated organic material from the surface of the seed layer **250**) [col. 5, line 63 to col. 6, line 6; and Fig. 3]; and
- (c) depositing a metal fill layer **455** (= the trench **253** is filled with the conductive material) on the rinsed metal seed layer by electrochemical deposition (= electroplating) [col. 6, lines 35-47; and Fig. 4].

The metal seed layer comprises a copper seed layer (col. 4, lines 63-67).

The providing a substrate having a metal seed layer comprises depositing the metal seed layer on the substrate by physical vapor deposition (col. 3, lines 29-36).

***Claim Rejections - 35 USC § 103***

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

Claim 4 is rejected under 35 U.S.C. 103(a) as being unpatentable over **Dubin et al.** (US Patent No. 7,001,641 B2) as applied to claims 1-3 above, and further in view of **Hymes** (US Patent No. 6,423,200 B1).

Dubin is as applied above and incorporated herein.

The method of Dubin differs from the instant invention because Dubin does not disclose wherein both the applying step and the depositing step are performed in the same chamber, as recited in claim 4.

Dubin teaches that unfortunately, as the substrate is transferred, the thin and delicate seed layer is often contaminated. For example, the seed layer, primarily of metal material, may oxidize as it is exposed to air during the transfer. Additionally, contaminants with organic material may occur, for example from the person transferring the substrate (col. 1, lines 49-63).

Like Dubin, Hymes teaches a seed layer treatment. Hymes teaches that applying

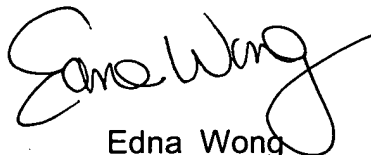
a chemical cleaning solution to the metal seed layer (col. 5, lines 1-13). A combined module **203** (= an electroplating apparatus) that allows the treating **204** (= the seed layer treatment module) and plating process **206** (= the electroplating module) to be performed in-situ and therefore, allow the plating process to occur just after the treatment of the seed layer (col. 4, lines 20-32; col. 5, lines 43-57; and Fig. 2A). This is well suited to perform the copper seed layer treatment in such a way that copper oxides are prevented from growing while wafers sit in a cassette before being electroplated with copper (col. 7, lines 8-18; and Figs. 2B and 2C).

It would have been obvious to one having ordinary skill in the art at the time the invention was made to have modified both the applying step and the depositing step described by Dubin with wherein both the applying step and the depositing step are performed in the same chamber because a combined module would have prevented copper oxides from growing on the substrate while being transferred from one treatment to another as taught by Hymes (col. 7, lines 8-18).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Edna Wong whose telephone number is (571) 272-1349. The examiner can normally be reached on Mon-Fri 7:30 am to 4:00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nam Nguyen can be reached on (571) 272-1342. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.



Edna Wong  
Primary Examiner  
Art Unit 1753

EW  
February 22, 2007